

Search Notes

Application/Control No.

10/649,287

Examiner

Edna Wong

Applicant(s)/Patent under
Reexamination

SALTIEL, JACK

Art Unit

1753

SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|-----------|----------|
| 204 | 157.67 | 8/31/2005 | EW |
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INTERFERENCE SEARCHED

| Class | Subclass | Date | Examiner |
|-------|----------|------------|----------|
| 204 | 157.67 | 11/30/2006 | EW |
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**SEARCH NOTES
(INCLUDING SEARCH STRATEGY)**

| | DATE | EXMR |
|-----------------------|------------|------|
| Inventor Search | 8/31/2005 | EW |
| EAST | 8/31/2005 | EW |
| STN | 8/31/2005 | EW |
| Search Updated | 11/23/2005 | EW |
| EAST | 11/26/2005 | EW |
| Search Updated | 4/29/2006 | EW |
| Google Scholar Search | 4/29/2006 | EW |
| Search Updated | 10/10/2006 | EW |